

Title (en)

Method and unit for washing a screen stencil frame used in a flat screen printing machine.

Title (de)

Verfahren und Einrichtung zum Waschen einer Siebschablone in einer Flachsiebdruckmaschine.

Title (fr)

Procédé et dispositif de lavage de pochoirs dans une machine de sérigraphie à pochoirs plats.

Publication

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Application

EP 85200188 A 19850212

Priority

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Abstract (en)

Disclosed is a method for washing a screen stencil frame in a flat screen printing machine, which comprises arranging a delivery member capable of reciprocally moving on the screen stencil frame, arranging a suction nozzle connected to a vacuum device on said delivery member, reciprocating the delivery member on the screen stencil frame in such a manner that the suction nozzle confronts a screen stencil of the screen stencil frame, and washing the screen stencil with water by utilizing a subatmospheric suction pressure generated by the suction nozzle.

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